WHAT IS CLAIMED IS:

1. An ablation method of applying a laser beam to a substrate on which a passivation film of nitride is formed, thereby performing ablation, said ablation method comprising:

a protective film forming step of applying a liquid resin containing a fine powder of oxide having absorptivity to the wavelength of said laser beam to at least a subject area of said substrate to be ablated, thereby forming a protective film containing said fine powder on at least said subject area of said substrate; and

a laser processing step of applying said laser beam to said subject area coated with said protective film, thereby performing ablation through said protective film to said subject area of said substrate after performing said protective film forming step.

2. The ablation method according to claim 1, wherein said fine powder of said oxide has an average particle size smaller than a spot diameter of said laser beam.

3. The ablation method according to claim 1, wherein

the wavelength of said laser beam is 355 nm or less;

said fine powder of said oxide includes a metal oxide selected from the group consisting of Fe_2O_3, ZnO, TiO_2, CeO_2, CuO, Cu_2O, and MgO; and

said liquid resin includes polyvinyl alcohol.

WHAT IS CLAIMED IS:

1. An ablation method, for a substrate on which a passivation film is laminated, of applying a laser beam to the substrate on which the passivation film of nitride is laminated, thereby performing ablation, the ablation method comprising:

a protective film forming step of applying a liquid resin containing a fine powder of oxide having absorptivity to a wavelength of the laser beam to at least a subject area of the substrate to be ablated, thereby forming a protective film containing the fine powder; and

a laser processing step of applying the laser beam to the subject area coated with the protective film, thereby performing ablation after performing the protective film forming step;

the fine powder of the oxide having an average particle size smaller than a spot diameter of the laser beam, and the spot diameter of the laser beam being set

to 10 μm or less;

the wavelength of the laser beam being set to 355 nm or less, the fine powder of the oxide including metal oxide selected from the group consisting of Fe_2O_3, ZnO, TiO_2, CeO_2, CuO, Cu_2O, and MgO, and the liquid resin including polyvinyl alcohol.